## **ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

Electronic Version v18 Stylesheet Version v18.0

Title of Invention

MULTI-RUN SELECTIVE PATTERN AND ETCH WAFER PROCESS

Application Number:

Confirmation Number:

First Named Applicant: Kenneth Bandy
Attorney Docket Number: BUR920020075US1

Search string:

( 6245581 or 6232134 or 5980766 or 5790254 or 5629772 ).pn.

## **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	6245581	2001-06-12	Bonser et al.		438	8
	2	6232134	2001-05-15	Farber et al.		438	9
	3	5980766	1999-11-09	Flamm et all.		216	59
	4	5790254	1998-08-04	Ausschnitt		356	372
	5	5629772	1997-05-13	Ausschnitt		256	372

## Signature

Examiner Name	Date